



US006617254B2

(12) **United States Patent**
Lee et al.

(10) **Patent No.:** **US 6,617,254 B2**
(45) **Date of Patent:** **Sep. 9, 2003**

(54) **METHOD FOR MANUFACTURING
CATHODE ELECTRODES OF
ELECTROLUMINESCENT DISPLAY DEVICE**

(75) Inventors: **Joo Hyeon Lee**, Kyongki-do (KR);
Woo Young Kim, Seoul (KR); **Sung
Hoo Ju**, Kyongki-do (KR); **Sun
Woong Kim**, Seoul (KR)

(73) Assignee: **Boe-Hydis Technology Co., Ltd.**,
Kyongki-do (KR)

(*) Notice: Subject to any disclaimer, the term of this
patent is extended or adjusted under 35
U.S.C. 154(b) by 0 days.

(21) Appl. No.: **09/993,746**

(22) Filed: **Nov. 6, 2001**

(65) **Prior Publication Data**

US 2002/0058420 A1 May 16, 2002

(30) **Foreign Application Priority Data**

Nov. 14, 2000 (KR) 2000-0067352

(51) **Int. Cl.⁷** **H01L 21/311**

(52) **U.S. Cl.** **438/702; 438/708**

(58) **Field of Search** 438/700, 702,
438/703, 708; 313/509, 512, 506

(56) **References Cited**

U.S. PATENT DOCUMENTS

5,448,133 A * 9/1995 Ise 313/497
5,688,551 A * 11/1997 Littman et al. 427/64
5,858,564 A * 1/1999 Tamura et al. 428/690
6,111,357 A * 8/2000 Fleming et al. 313/509

FOREIGN PATENT DOCUMENTS

JP 9-82476 * 3/1997

* cited by examiner

Primary Examiner—Kin-Chan Chen

(74) *Attorney, Agent, or Firm*—Ladas & Parry

(57) **ABSTRACT**

Disclosed is a method for manufacturing cathode electrodes of electroluminescent display device capable of forming cathode electrodes of fine patterns. The disclosed comprises the steps of: forming an anode electrode on a transparent insulating substrate; forming an insulating partition having a stripe structure to cross with the anode electrode and define a pixel formation area on the substrate; forming an organic film pixel separated with a predetermined distance, with the insulating partition interposed; depositing a cathode metal layer on the surface of the resulting structure; and forming a cathode electrode exposing a predetermined part of the insulating partition by performing etching processes on the cathode metal layer using laser.

5 Claims, 6 Drawing Sheets

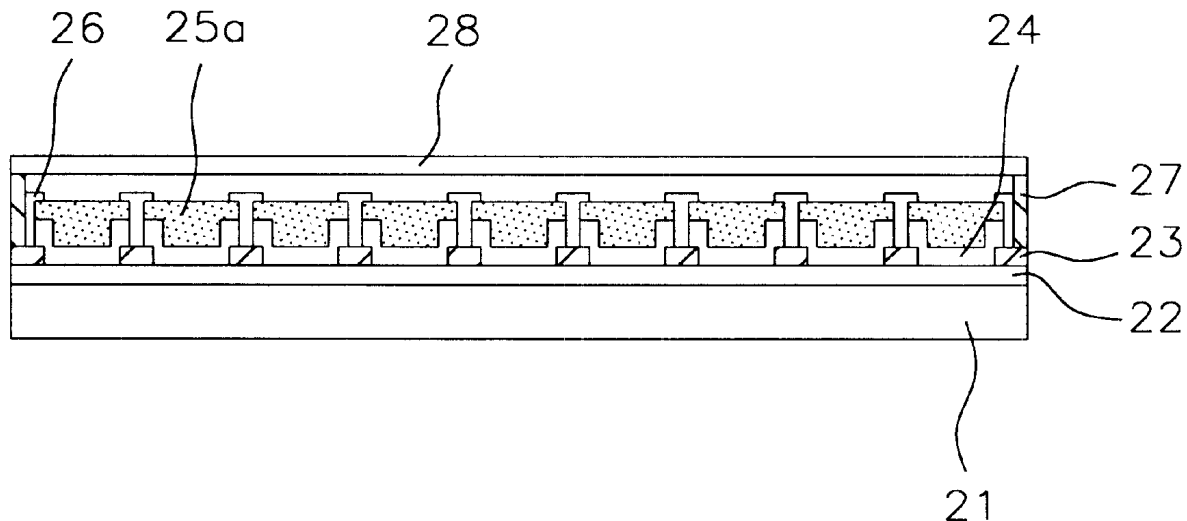


FIG. 1A
(PRIOR ART)

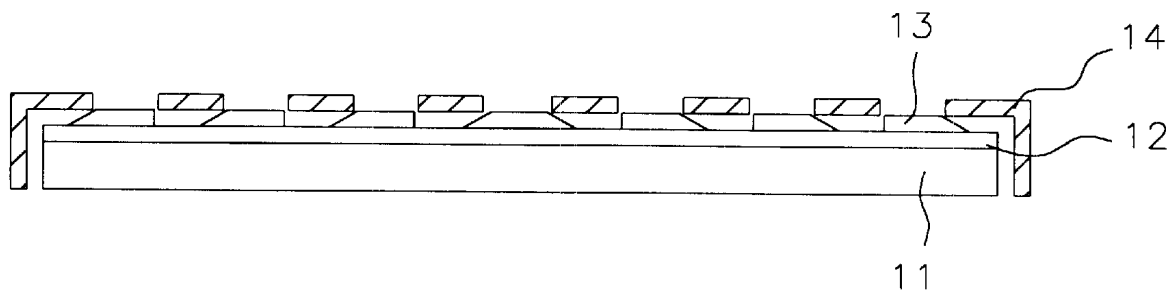


FIG. 1B
(PRIOR ART)

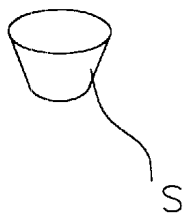
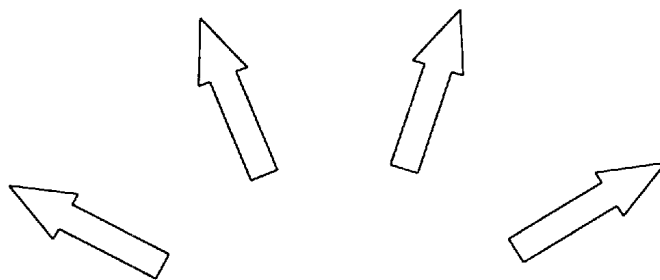
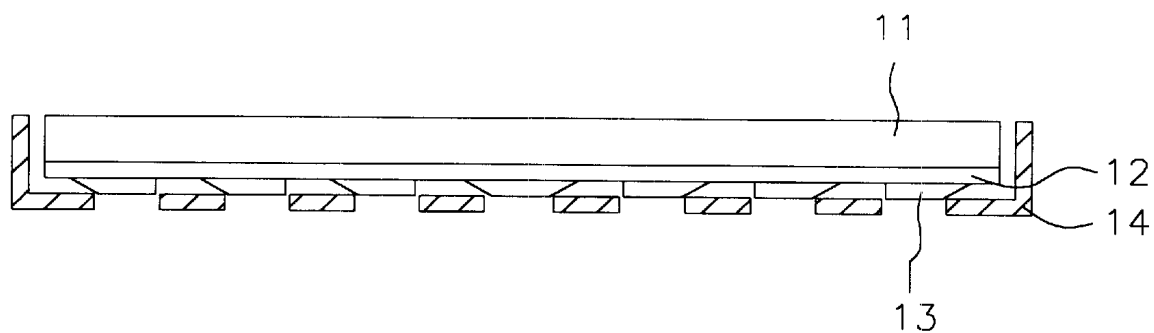


FIG. 2
(PRIOR ART)

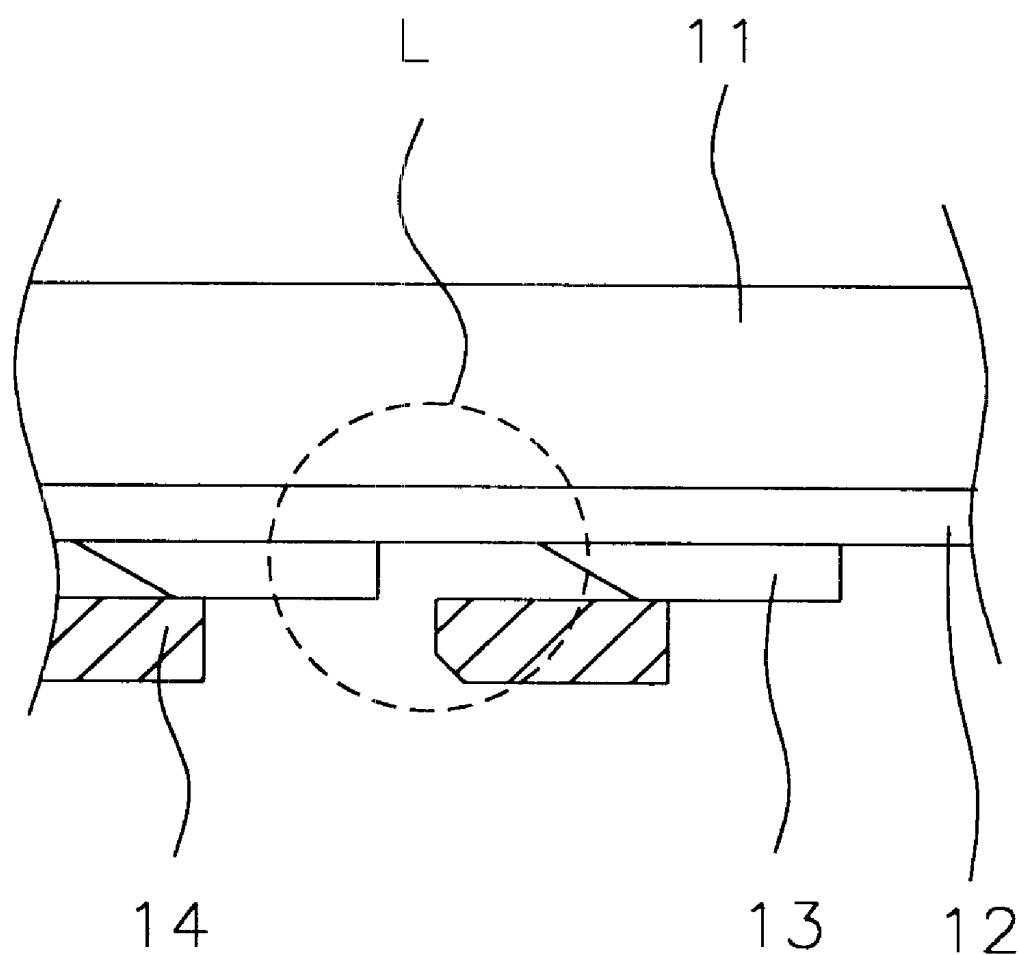


FIG.3
(PRIOR ART)

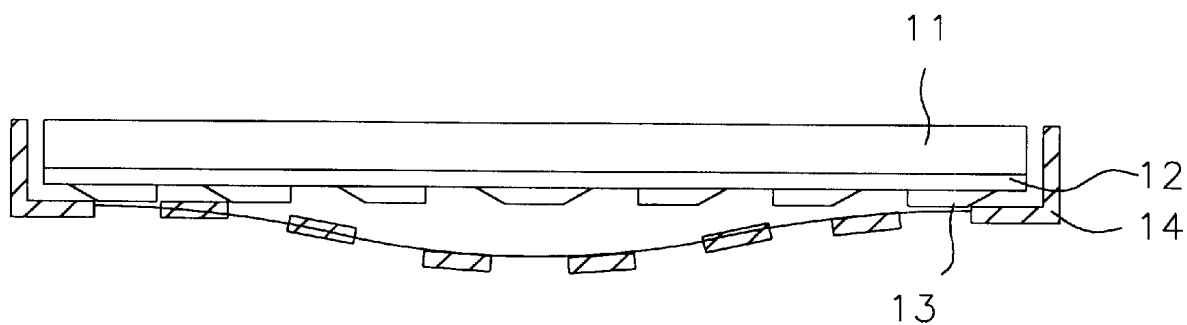


FIG.4

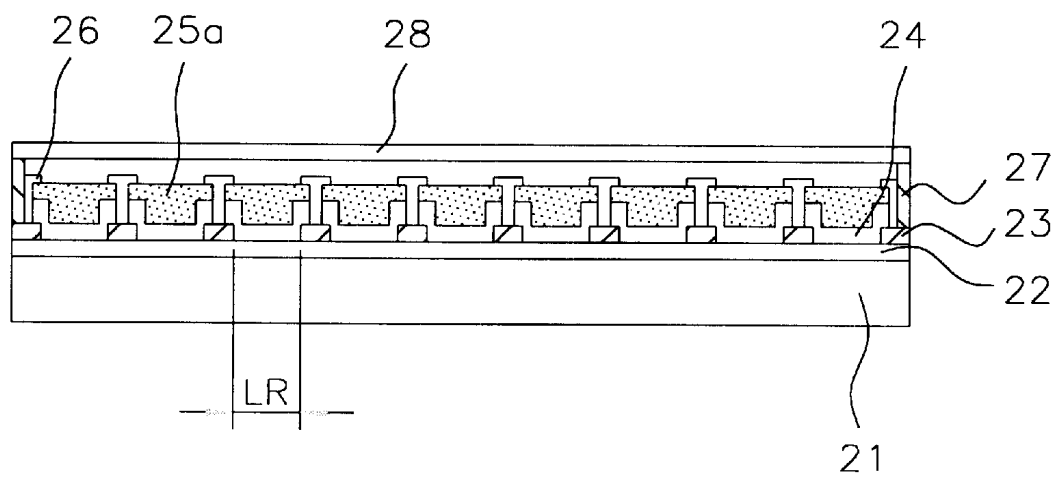


FIG. 5A

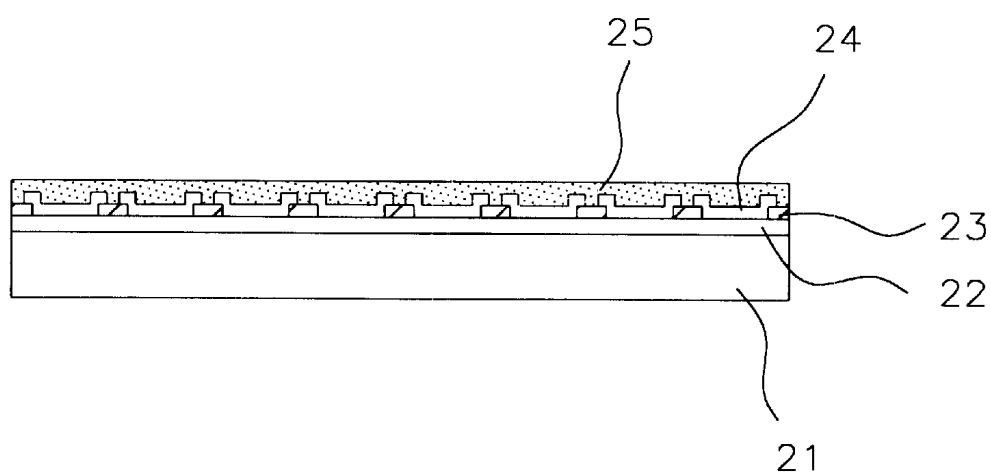


FIG. 5B

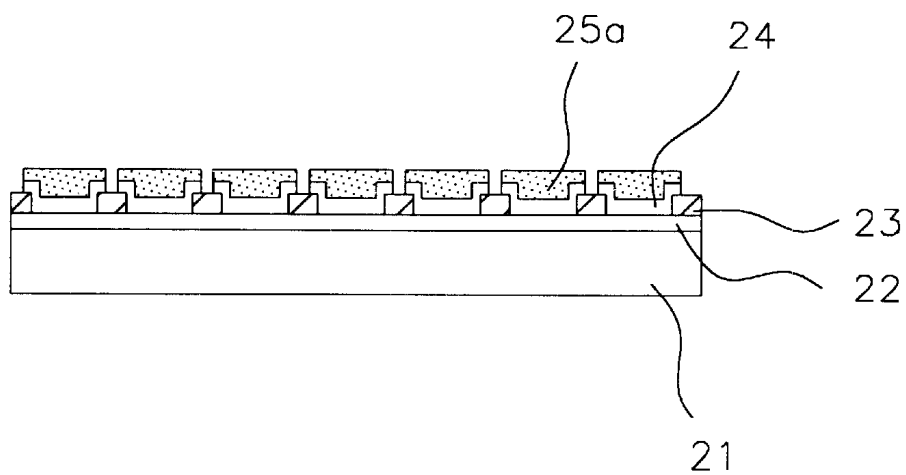


FIG. 5C

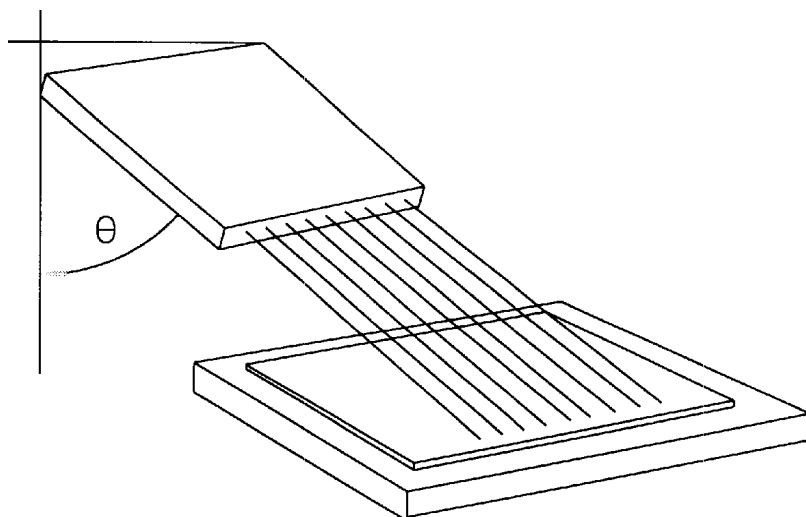


FIG. 5D

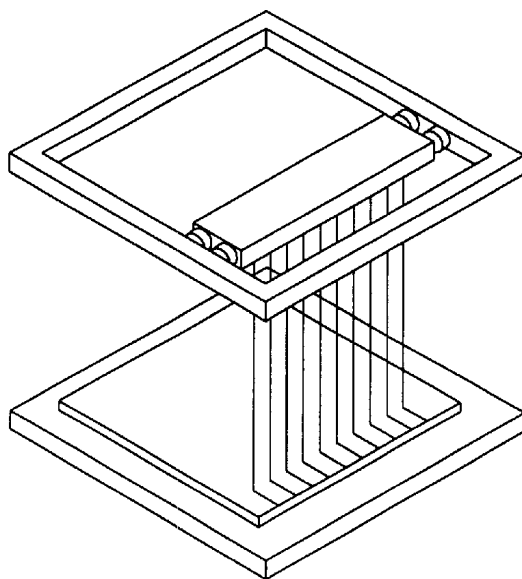
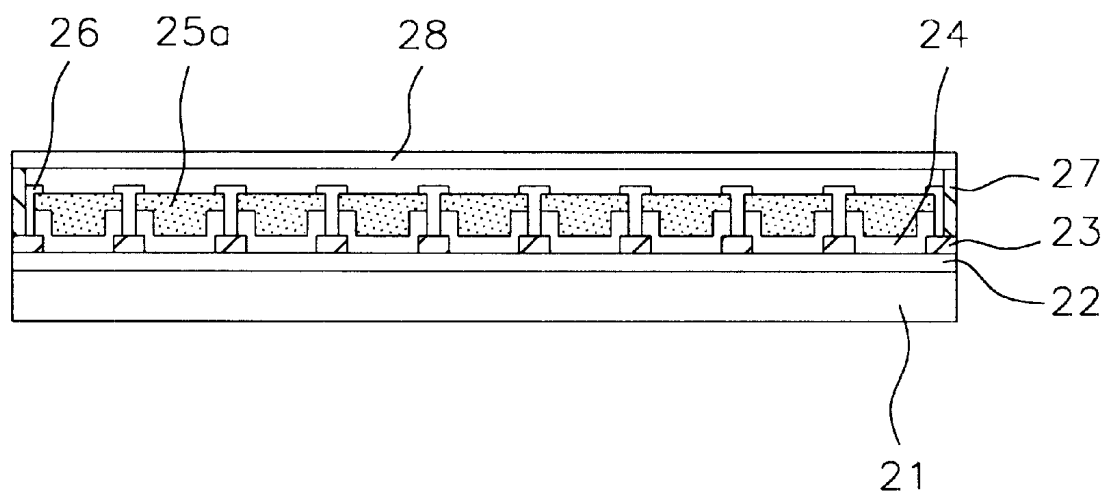


FIG. 5E



1

METHOD FOR MANUFACTURING CATHODE ELECTRODES OF ELECTROLUMINESCENT DISPLAY DEVICE

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to a method for Manufacturing electroluminescent display device, and more particularly, to a method for manufacturing cathode electrodes of electroluminescent display device capable of forming cathode electrodes having fine patterns.

2. Description of the Related Art

As a next generation display, self-luminescent organic electroluminescent (hereinafter referred to as EL) devices have a structure that an anode electrode, an organic thin film layer and a cathode electrode are sequentially deposited on a transparent substrate. In the passive matrix panel, the size of pixels depends on the line width of cathode electrodes and anode electrodes crossing each other and in order to obtain high resolution organic EL panel, anode pixel electrodes and cathode metal layers are formed to have a fine pattern. The pixel electrodes accomplish the fine pattern by using lithography process and the cathode electrodes by using shadow mask or by forming cathode separation partition without mask.

However, it is difficult to pattern the cathode by using the cathode separation partition since a Japanese organic panel maker, pioneer has a patent right for the method.

FIGS. 1A and 1B are cross-sectional views for showing a conventional method for manufacturing cathode electrodes of electroluminescent display device.

Referring to FIG. 1A, first, a transparent insulating substrate 11 is prepared, wherein an anode electrode 12 and an organic film layer 13 are formed in a stripe shape. Then, a shadow mask 14 is provided to form succeeding cathode electrode pattern on the organic film layer 13.

Referring to FIG. 1B, the transparent insulating substrate 11 including the anode electrode 12 and the organic film layer 13 is put into a vacuum deposition device, the organic film layer 13 being downward. Subsequently, evaporated metal ions are deposited on the transparent insulating substrate 11 having the shadow mask 14 from a metal source unit S on the lower part of the vacuum deposition device and then, pattern etch is performed to obtain a cathode electrode. As a result, the fabrication is completed for electroluminescent display device as organic EL device.

FIGS. 2 and 3 are cross sectional views for showing problems of conventional methods for fabricating cathode electrodes of electroluminescent display device.

The conventional methods for fabricating cathode electrodes of electroluminescent display device will be described referring to the FIGS. 2 and 3.

First, according to the conventional method for fabricating cathode electrodes by using shadow mask, it is required to maintain accurate contact of alignment of shadow mask and transparent insulating substrate with shadow mask. Therefore, as the size of pixel becomes small and that of panel is increased, it is difficult to be used due to misalignment of shadow mask and inaccurate contact of transparent insulating substrate and shadow mask.

Second, as shown in FIG. 2, metal ions evaporated by the misalignment are flowed into the gap L between the shadow mask 14 and the organic film layer 13, thereby generating shorts with the anode electrode 12.

2

Finally, as shown in FIG. 3, when the transparent insulating substrate 11 having the shadow mask 14 is put into the vacuum deposition device, the center of the shadow mask 14 is hanging down due to the large panel, thereby generating shorts with the cathode electrode and the anode electrode. Therefore, there are problems that the shadow mask should be formed with a material having strong magnetism and additional devices are required to tightly support the shadow mask on all sides.

SUMMARY OF THE INVENTION

Therefore, the present invention has been made to solve the above problems and the object of the present invention is to provide a method for manufacturing cathode electrodes of electroluminescent display device capable of forming fine pattern cathode electrodes using laser.

In order to accomplish the above object, the present invention comprises the steps of: providing an anode electrode on a transparent insulating substrate; forming a separation partition having a stripe structure to cross with the anode electrode and define a pixel formation area on the substrate; forming organic film pixels separated from each other with insulating partition interposed; depositing a cathode metal layer on the surface of the resulting structure; and performing etching processes on the cathode metal layer by using laser to form a cathode electrode exposing a predetermined part of the insulating partition.

The etching process using laser is performed to remove the cathode metal layer by rotating the laser downward from a horizontal axis in the range of 0~180°. Here, the laser is controlled in a rotation manner.

And, the etching process using laser is performed by moving back and forth with the laser fixed vertically downward.

The absorbent is BaO or Y₂O₃ of oxide series.

After the cathode electrode is formed, the present invention further comprises the steps of: forming absorbent between cathode electrodes on the insulating partition to prevent humidity; applying UV hardening resin for protection on the upper part of edge of the insulating partition; and forming capsule on the upper part of the UV hardening resin.

BRIEF DESCRIPTION OF THE DRAWINGS

FIGS. 1A and 1B are cross sectional views for showing a conventional method for manufacturing cathode electrodes of electroluminescent display device.

FIGS. 2 and 3 are cross sectional views for showing problems of the conventional method for manufacturing cathode electrodes of electroluminescent display device.

FIG. 4 is a cross sectional view of electroluminescent display device according to the present invention.

FIGS. 5A to 5E are cross sectional views for showing a method for manufacturing cathode electrodes of electroluminescent display device.

DETAILED DESCRIPTION OF THE INVENTION

The above objects, and other features and advantages of the present invention will become more apparent after reading the following detailed description when taken in conjunction with the drawings.

FIG. 4 is a cross sectional view of electroluminescent display device according to the present invention.

Referring to the FIG. 4, the present invention has a shape that a plurality of anode electrode patterns 22 of stripe structure are formed on the upper part of a transparent insulating substrate 21.

An insulating partition **23** is formed to prevent generation of shorts between the anode electrode and cathode electrode, crossing with the anode electrode patterns **22** on the transparent insulating substrate **21** having the anode electrode patterns **22** and an organic film pixel **24** comprising a hole transporting layer, a luminescent layer and an electron transporting layer is formed on the transparent insulating substrate **21** exposed by the insulating partition.

And, a cathode electrode pattern **25a** is formed on the upper part of the organic film pixel **24** and an absorbing layer **26** is formed between the cathode electrode patterns **25a** on the insulating partition **23**.

And, UV hardening resin for protection **27** is applied on the edge of the insulating partition **23** and a capsule **28** is formed on the UV hardening resin **27**.

The absorbing layer **26** is formed with BaO or Y₂O₃.

As shown in FIG. 4, when negative voltage is applied to the cathode electrode **25a** and positive voltage to the anode electrode **22**, the light is radiated through luminescent region LR of pixel between the insulating partition **23**.

FIGS. 5A to 5E are cross sectional views for showing a method for manufacturing cathode electrodes of electroluminescent display device according to the present invention.

Referring to FIG. 5A, first, Indium Tin Oxide ITO is deposited as an anode pixel electrode on a transparent insulating substrate **21** and then, pattern etch processes are performed on the anode pixel electrode to form a plurality of anode electrode patterns **22** having a stripe shape.

Subsequently, an insulating partition **23** having a stripe shape is formed to cross with the anode electrode pattern **22** on the resulting structure.

Then, an organic film pixel **24** comprising a hole transporting layer, a luminescent layer and an electron transporting layer is formed on the substrate including the insulating partition **23**. The organic film pixel **24** is formed, separated from each other with the insulating partition **23** interposed.

Afterwards, a cathode metal layer **25** is deposited on the surface of the transparent insulating substrate **21** including the organic film pixel **24** and the insulating partition **23**.

Referring to FIG. 5B, a cathode electrode pattern **25a** is formed on the surface of the substrate **21** by performing pattern etch processes on the cathode metal layer. The cathode electrode pattern **25a** is formed using a cutting feature of laser, that is, the cathode metal layer **25** deposited on the surface is etched with a desirable cathode electrode pattern gap by using laser without mask and the cathode metal layer **25** connecting each pixel is etched to expose the insulating partition **23**.

FIGS. 5C and 5D are drawings for showing pattern manners of cathode electrode performing etching process on cathode metal layer by using laser irradiation.

FIG. 5C shows a manner of patterning the cathode electrode by rotating laser horizontally downward on the horizontal axis to a predetermined angle Θ in the range of 0~180° with one end fixed and FIG. 5D shows a manner of patterning the cathode electrode by moving laser fixed vertically downward to the horizontal direction.

According to the above manners, it is possible to control etching thickness by power and moving speed of laser and control pattern width of cathode electrode by irradiation angle of laser.

Referring to FIG. 5E, an absorbing layer **26** for preventing humidity is formed between the cathode electrode patterns **25a** on the insulating partition **23**.

The absorbing layer **26** is provided for prevention of humidity and of short generation in a metal line to improve stability in each pixel. The absorbing layer **26** is BaO or Y₂O₃ of oxide series.

Finally, a UV hardening resin **27** for protection is applied on the upper part of the edge of the insulating partition **23** and a capsule **28** is formed on the UV hardening resin **27**, thereby completing fabrication of electroluminescent display device according to the present invention.

As described above, according to the present invention, cathode electrode patterns are formed by etching cathode metal layer using laser without a shadow mask. Therefore, it is possible to be employed without regard to the size of substrate.

And, it is possible to prevent deterioration of short between electrodes due to inaccurate contact since the shadow mask is not used. Moreover, it is also possible to prevent pollution of chamber generated in the change of shadow mask, thereby simplifying manufacturing processes and reducing the cost.

And, cathode electrode patterns are formed using laser and then absorbent is prepared on the etched part, thereby preventing humidity in pixels and improving reliability of device.

Although the preferred embodiments of the invention have been disclosed for illustrative purposes, those skilled in the art will appreciate that various modifications, additions and substitutions are possible, without departing from the scope and spirit of the invention as disclosed in the accompanying claims.

What is claimed is:

1. A method for manufacturing cathode electrodes of electroluminescent display device comprising the steps of:

forming an anode electrode on a transparent insulating substrate;

forming an insulating partition having a stripe structure to cross with the anode electrode and define a pixel formation area on the substrate;

forming an organic film pixel separated with a predetermined distance, with the insulating partition interposed;

depositing a cathode metal layer on the surface of the resulting structure; and

forming a cathode electrode exposing a predetermined part of the insulating partition by performing etching processes on the cathode metal layer using laser.

2. The method for manufacturing cathode electrodes of electroluminescent display device according to claim 1, wherein the etching process using laser is performed to remove the cathode metal layer by controlling the laser in a rotation manner and by rotating the laser downward from a horizontal axis in the range of 0~180°.

3. The method for manufacturing cathode electrodes of electroluminescent display device according to claim 1, wherein the etching process using laser is performed by moving back and forth with the laser fixed vertically downward.

4. The method for manufacturing cathode electrodes of electroluminescent display device according to claim 1, further comprising the steps of:

forming an absorbent for prevention of humidity between the cathode electrodes on the insulating partition;

applying UV hardening resin for protection on the edge of the insulating partition; and

forming a capsule on the upper part of the UV hardening resin.

5. The method for manufacturing cathode electrodes of electroluminescent display device according to claim 4, wherein the absorbent is BaO or Y₂O₃ of oxide series.

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,617,254 B2
DATED : September 9, 2003
INVENTOR(S) : Joo Hyeon Lee et al.

Page 1 of 1

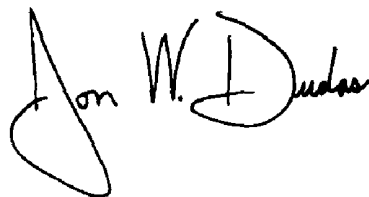
It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title page,

Item [*] Notice, the Patent Term Adjustment is -- 116 days --

Signed and Sealed this

Twenty-fourth Day of May, 2005

A handwritten signature in black ink, appearing to read "Jon W. Dudas". The signature is stylized with a large, looping initial "J" and a distinct "D".

JON W. DUDAS
Director of the United States Patent and Trademark Office

专利名称(译)	制造电致发光显示装置的阴极的方法		
公开(公告)号	US6617254	公开(公告)日	2003-09-09
申请号	US09/993746	申请日	2001-11-06
[标]申请(专利权)人(译)	李宙铉 金宇YOUNG JU SUNG HOO 金顺WOONG		
申请(专利权)人(译)	李宙铉 金宇YOUNG JU SUNG HOO 金顺WOONG		
当前申请(专利权)人(译)	BOE-HYDIS TECHNOLOGY CO. , LTD.		
[标]发明人	LEE JOO HYEON KIM WOO YOUNG JU SUNG HOO KIM SUN WOONG		
发明人	LEE, JOO HYEON KIM, WOO YOUNG JU, SUNG HOO KIM, SUN WOONG		
IPC分类号	H01L27/28 H01L27/32 H05B33/10 H01L51/50 H01L51/52 H01L51/56 H05B33/22 H01L21/311		
CPC分类号	H01L51/0017 H01L51/0021 H01L51/0023 H01L51/5221 H01L51/56 H01L27/3281 H01L51/5237 H01L51/5259		
代理机构(译)	LADAS & PARRY		
优先权	1020000067352 2000-11-14 KR		
其他公开文献	US20020058420A1		
外部链接	Espacenet USPTO		

摘要(译)

公开了一种制造能够形成精细图案的阴极电极的电致发光显示装置的阴极电极的方法。所公开的步骤包括：在透明绝缘基板上形成阳极；形成具有条形结构的绝缘隔板，以与阳极电极交叉，并在基板上形成像素形成区域；形成以预定距离分开的有机薄膜像素，其中插入绝缘隔板；在所得结构的表面上沉积阴极金属层；通过使用激光在阴极金属层上执行蚀刻工艺，形成暴露绝缘隔板的预定部分的阴极电极。

